

# **Self-consistent model of charge-carrier injection: extension to the case of a degenerate organic semiconductor**



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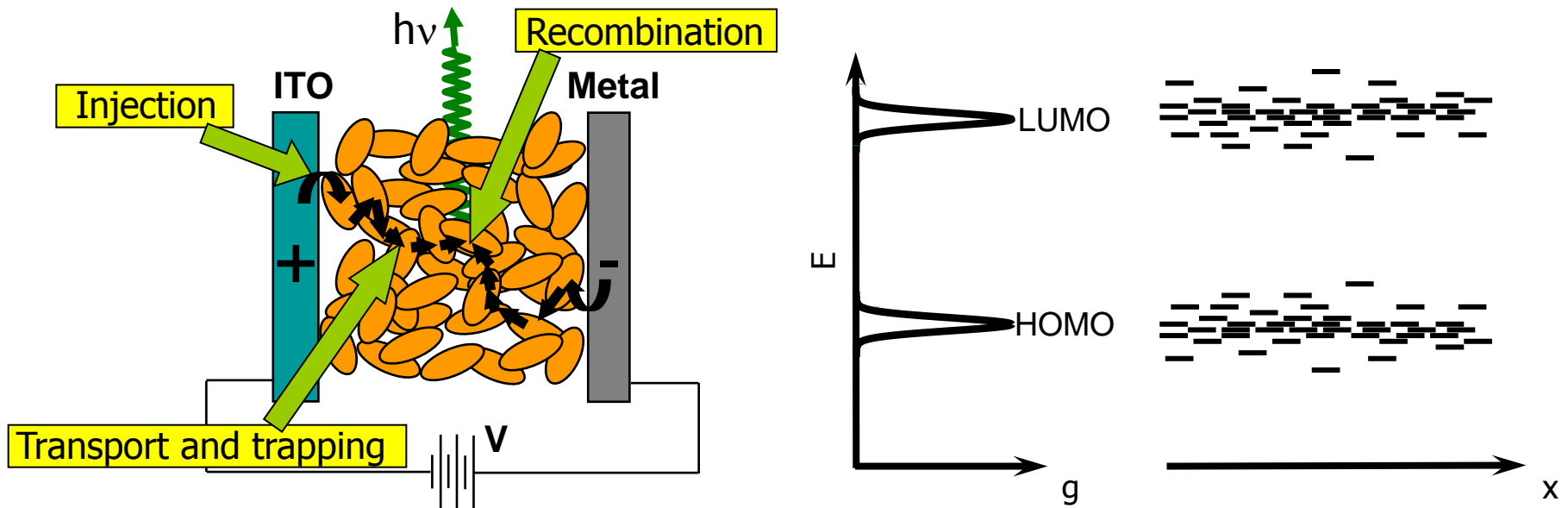
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- Outline of the previous self-consistent model of charge-carrier injection and transport accounting for discrete nature of charge carriers (MMF approach)
- Approximations for the charge-carrier density in the case of Gaussian DOS
- Extension of the MMF model to the case of degenerate semiconductor: voltage-barrier chart, current-voltage characteristics for unipolar devices
- Conclusion

# Important factors of electronic processes in organic semiconductors and our aims



- We need in a **self-consistent model of charge injection and transport** in organic semiconductors allowing to extract from experiments important **device parameters** (carrier concentrations, mobilities, injection barriers, field distribution) and to **evaluate the fatigue stability** of specific devices

# Self-consistent 1D mean-field model of charge-carrier injection and unipolar transport in a single-layer device

## Keypoints of the model

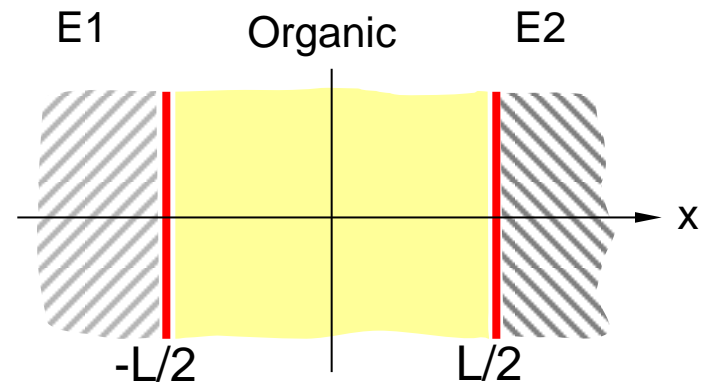
### A. Organic semiconductor:

$$kT \mu_i \frac{dp_i(x)}{dx} - e \mu_i p_i(x) F_i(x) = -j$$

$$\frac{dF_i(x)}{dx} = \frac{e}{\varepsilon_i \varepsilon_0} p_c(x)$$

**narrow** DOS:  $g(E) = P_c \delta(E - E_c)$

**Boltzmann statistics** of the carriers:  $p_i(x) = P_c \exp \left[ \frac{E_c - \kappa_i(x) - e\varphi(x)}{kT} \right]$



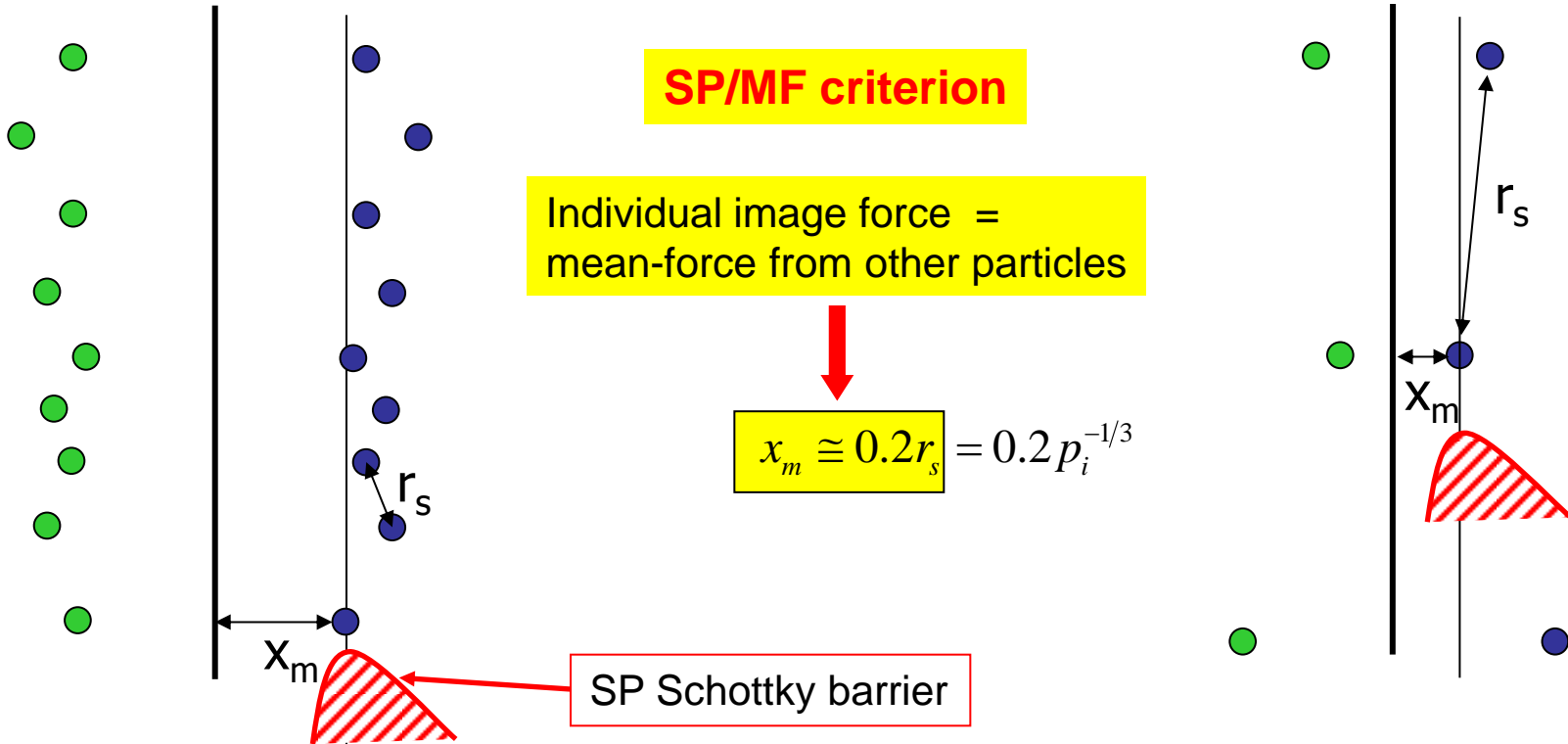
### B. Electrodes: Thomas-Fermi approximation

### C. Self-consistent boundary conditions at the electrode/OSC interfaces:

- electric displacement and electrochemical potential are **continuous**
- electrostatic potential is continuous (mean-field (MF) approach) or has a jump  $\Delta\varphi_e = \delta\varphi_{Sch}$  (modified mean-field (MMF) model)

Neumann et al. JAP **100**, 084511 (2006); Genenko et al., PRB **81**, 125310(2010)

# Charge-carrier injection: many-particle vs single-particle (SP) mechanism

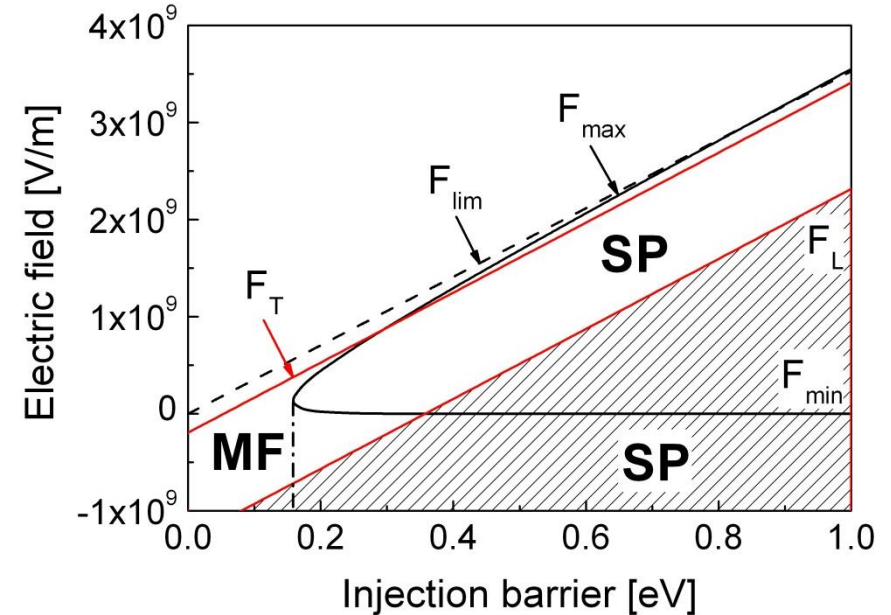
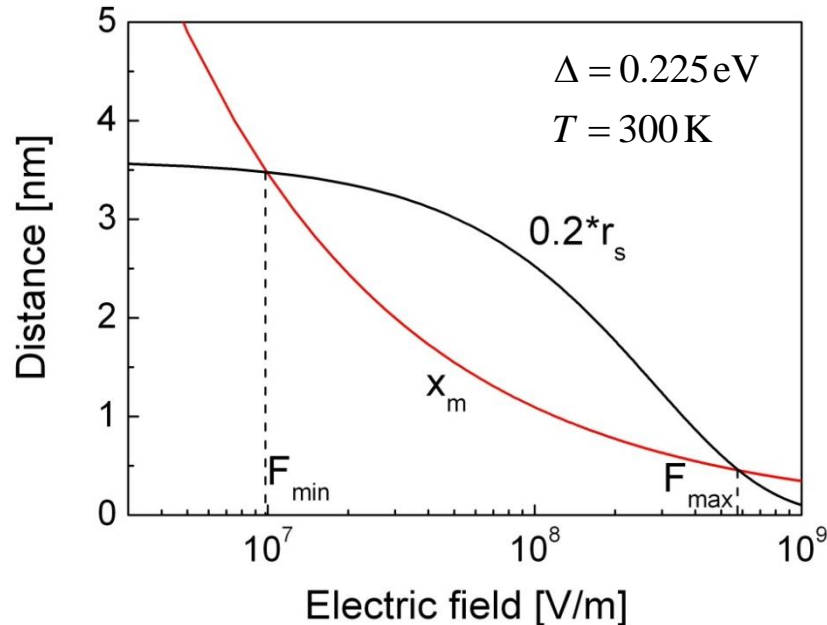


$$x_m^\pm = \sqrt{\frac{e}{16\pi\epsilon_0\epsilon_i |F_i(\pm L/2)|}}$$

$$p_i(\pm L/2) = P_c \exp \left\{ -\frac{\Delta^\pm}{kT} \mp \frac{el_{TF}^\pm}{kT} \left[ \frac{\epsilon_i}{\epsilon_e^\pm} F_i(\pm L/2) - \cancel{\frac{j}{j_e^\pm}} \right] \right\}$$

Genenko et al., PRB **81**, 125310(2010)

# Validity of SP and MF approximations: field region



ITO	Organic
$n_{\infty}^{-} = 10^{20} \text{ cm}^{-3}$	$P = 10^{21} \text{ cm}^{-3}$
$\epsilon_e^{-} = 9.3$	$\epsilon_i = 3$
$\mu_e^{-} = 30 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$	$\mu_p = 10^{-4} \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$
$\kappa_{\infty}^{-} = 0.225 \text{ eV}$	

Additionally:

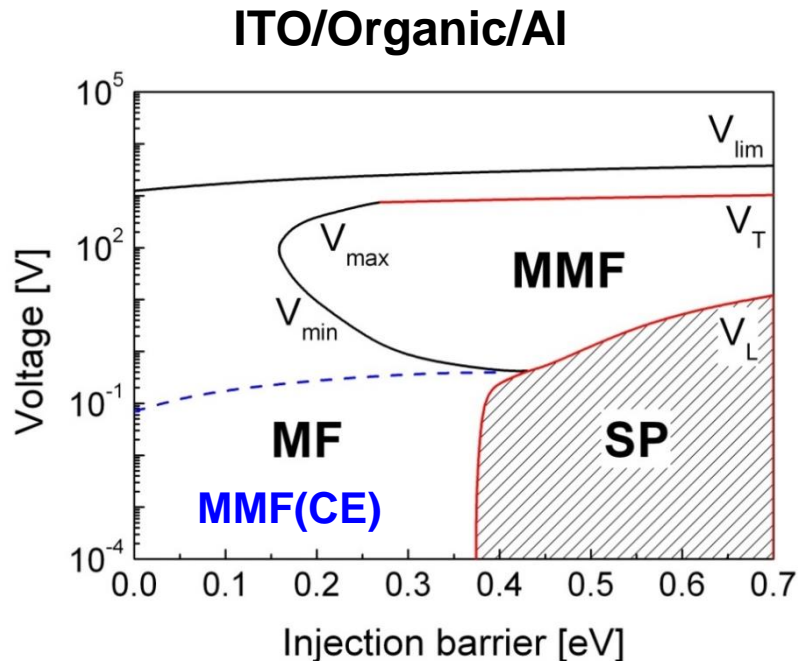
$$r_s = L \Rightarrow F_L$$

$$r_s = l_{\text{Coulomb}} = e^2 / 32\pi\epsilon_0\epsilon_i kT \Rightarrow F_T$$

# Account of charge-carrier discreteness in the MF approach

Boundary conditions:

$$p_i(\pm L/2) = P_c \exp \left[ -\frac{\Delta^\pm}{kT} m \frac{eF_i(\pm L/2)l_{TF}^\pm}{kT} \frac{\epsilon_i}{\epsilon_e^\pm} + \left( 1 - \frac{x_m^\pm}{0.2r_s^\pm} \right) \frac{e\delta\varphi_{sch}^\pm}{kT} \theta(0.2r_s^\pm - x_m^\pm) \right]$$



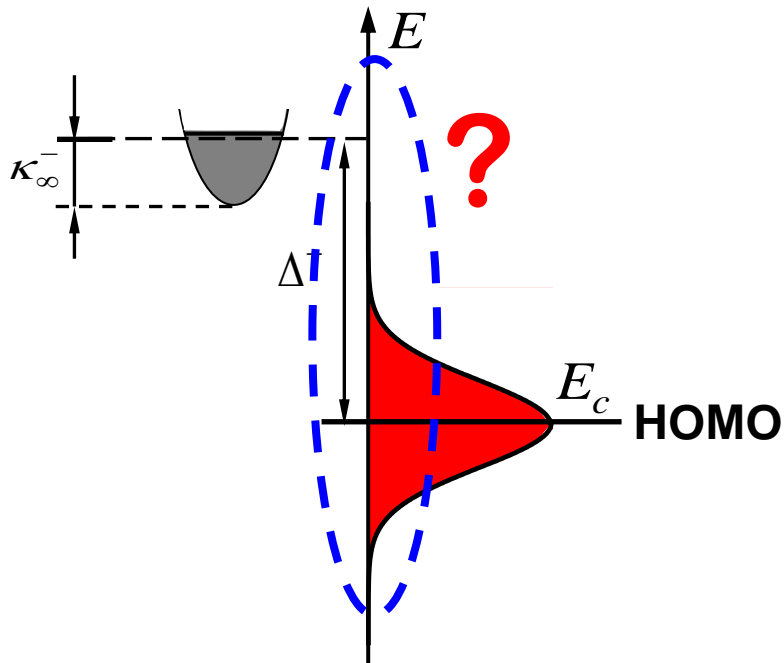
$$V = \int_{-\infty}^{\infty} dx F(x) - V_{BI}$$

$$V_{BI} = \int_{-\infty}^{\infty} dx F(x) \Big|_{j=0}$$

Genenko et al., PRB **81**, 125310(2010)

# What changes for the Gaussian DOS?

## ITO/OSC interface



$$p_i(x) = \int_{-\infty}^{\infty} dE g(E) f(E, \kappa_i(x))$$

$$= \frac{P_c}{\sqrt{2\pi}\sigma_c} \int_{-\infty}^{\infty} dE \frac{\exp\left(-\frac{(E - E_c)^2}{2\sigma_c^2}\right)}{\exp\left(\frac{\kappa_i(x) + e\phi(x) - E}{kT}\right) + 1}$$

In the „Boltzmann regime“:

$$\Delta^\pm \rightarrow \Delta^\pm - \frac{\sigma_c^2}{2kT}$$

- Whether the Boltzmann statistics of carriers is still relevant in the case of realistic Gaussian DOS of OSC, especially for calculation of the carrier density at the electrode/OSC interfaces?



# Charge-carrier density as Gauss-Fermi integral



Paasch & Scheinert, JAP **107**, 104501 (2010)

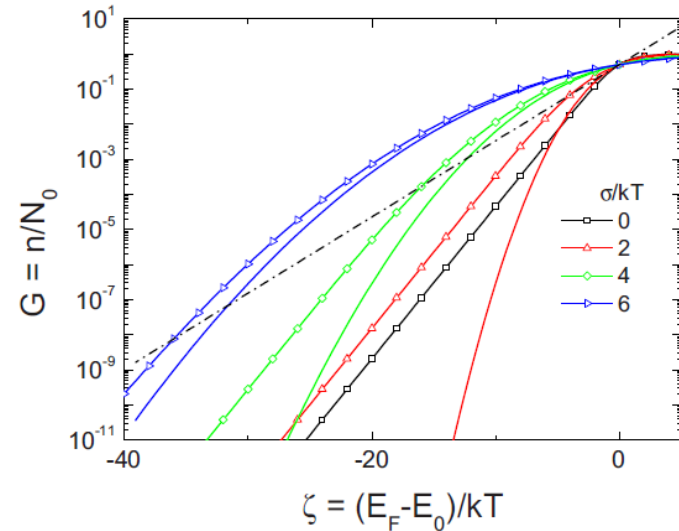
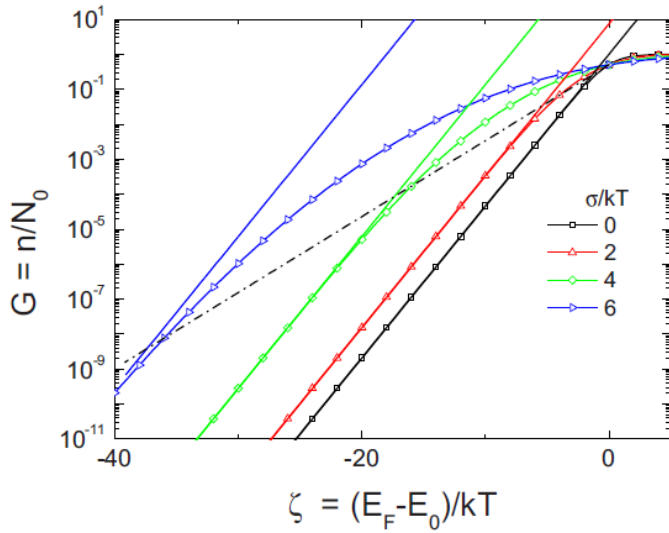
$$n = \int dE g(E) f(E, E_F) = \frac{N_0}{\sqrt{2\pi}\sigma} \int_{-\infty}^{\infty} dE' \exp\left(-\frac{E'^2}{2\sigma^2}\right) \left[ \exp\left(\frac{E' - E_F + E_0}{kT}\right) + 1 \right]^{-1}$$

Nondegenerate limit:  $f(E, E_F) \rightarrow \exp\left(\frac{E_F - E}{kT}\right)$

$$n = N_0 \exp\left(\frac{E_F - E_0}{kT} + \frac{\sigma^2}{2(kT)^2}\right)$$

Degenerate limit:  $f(E, E_F) \rightarrow \theta(E_F - E)$

$$n = \frac{N_0}{2} \operatorname{erfc}\left(-\frac{E_F - E_0}{\sigma\sqrt{2}}\right)$$



Crossover at  $\zeta = -\frac{\sigma^2}{2(kT)^2}$  :  $n_{cr} = \frac{N_0}{2} \exp\left(-\frac{\sigma^2}{2(kT)^2}\right)$

For  $\sigma(300\text{K}) = 0.1 \text{ eV}$   $n_{cr} \sim 10^{-4} N_0$

# PS analytical approximation for GF integral

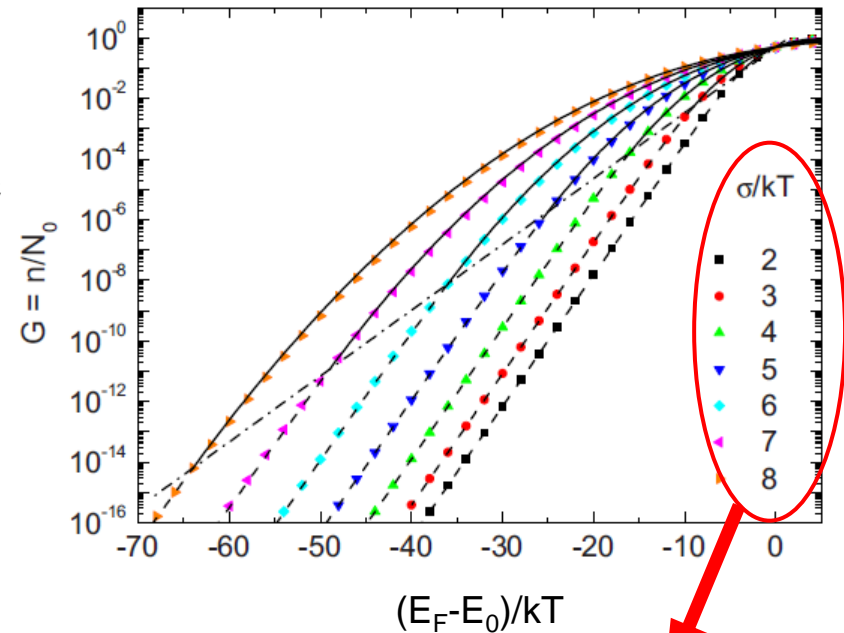
Paasch & Scheinert, JAP **107**, 104501 (2010)

$$\zeta = \frac{E_F - E_0}{kT}, \quad s = \frac{\sigma}{kT}$$

$$\frac{n}{N_0} = \begin{cases} \exp\left(\zeta + \frac{s^2}{2}\right) \left[ \exp\left(K(s)(\zeta + s^2)\right) + 1 \right]^{-1}, & \zeta \leq -s^2 \\ \frac{1}{2} \operatorname{erfc}\left(-\frac{\zeta}{s\sqrt{2}} H(s)\right), & \zeta \geq -s^2 \end{cases}$$

$$H(s) = \frac{\sqrt{2}}{s} \operatorname{erfc}^{-1}\left[\exp\left(-\frac{s^2}{2}\right)\right]$$

$$K(s) = 2 \left\{ 1 - \frac{H}{s} \sqrt{\frac{2}{\pi}} \exp\left[\frac{s^2}{2}(1 - H^2)\right] \right\}$$



$$\sigma_c(300\text{K}) = 0.05 - 0.2 \text{ eV}$$

- After appropriate modifications this approximation can be applied to the MMF boundary conditions

# MMF boundary conditions in the case of Gaussian DOS

Self-consistent boundary conditions at the electrode/OSC interfaces are:

$$p_i\left(\pm\frac{L}{2}\right) = \frac{P_c}{\sqrt{2\pi}\sigma_c} \int_{-\infty}^{\infty} dE \exp\left(-\frac{E^2}{2\sigma_c^2}\right) \left[ \exp\left(\frac{\Delta_{eff}^{\pm} - E}{kT}\right) + 1 \right]^{-1}$$

$$\Delta_{eff}^{\pm} = \Delta^{\pm} \pm e l_{TF}^{\pm} \left( \frac{\varepsilon_i}{\varepsilon_e} F(\pm L/2) - \frac{j}{\gamma_e^{\pm}} \right) - \left( 1 - \frac{x_m^{\pm}}{0.2r_s^{\pm}} \right) e \delta\varphi_{sch}^{\pm} \theta(0.2r_s^{\pm} - x_m^{\pm})$$

With substitutions  $\zeta\left(\pm\frac{L}{2}\right) = \frac{\Delta_{eff}^{\pm}}{kT}$ ,  $s = \frac{\sigma_c}{kT}$ :

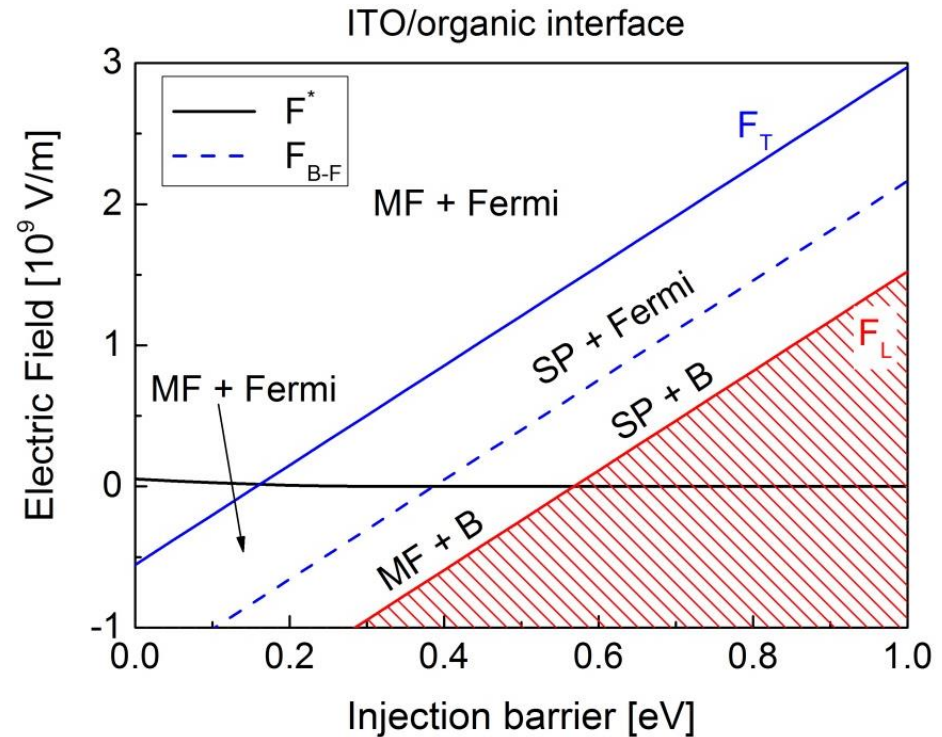
$$\frac{p_i(\pm L/2)}{P_c} = \begin{cases} \exp\left(\zeta\left(\pm\frac{L}{2}\right) + \frac{s^2}{2}\right) \left[ \exp\left(K(s)\left(\zeta\left(\pm\frac{L}{2}\right) + s^2\right)\right) + 1 \right]^{-1}, & \zeta\left(\pm\frac{L}{2}\right) \geq s^2 \\ \frac{1}{2} \operatorname{erfc}\left(-\frac{\zeta(\pm L/2)}{s\sqrt{2}}\right) H(s), & \zeta\left(\pm\frac{L}{2}\right) \leq s^2 \end{cases}$$

# Field-injection barrier chart

$$x_m = 0.2 p_i^{-1/3} \Rightarrow F^*$$

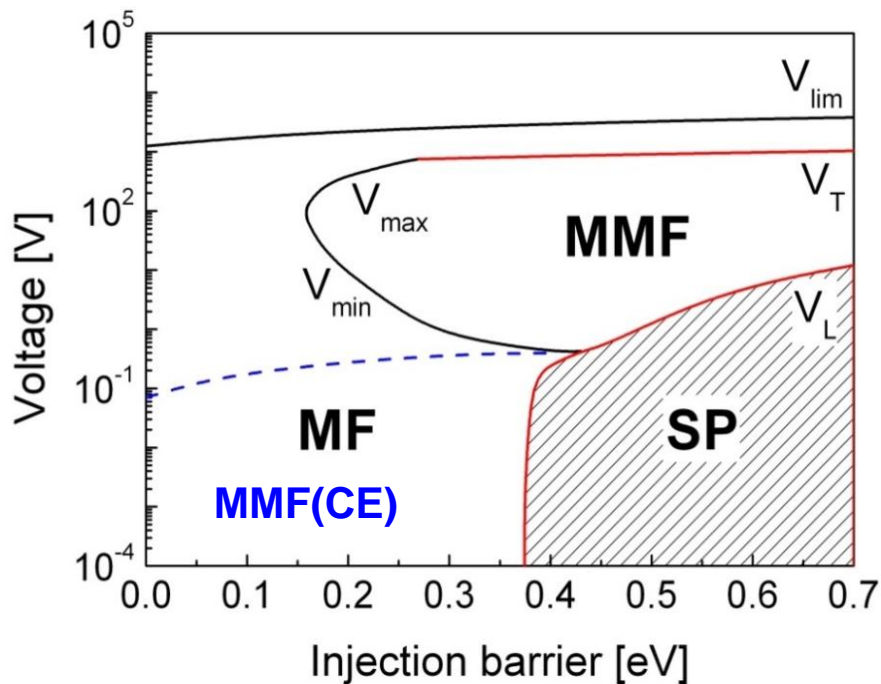
$$\Delta^- - e l_{TF}^- \left( \frac{\varepsilon_i}{\varepsilon_e^-} F(-L/2) - \frac{j}{\gamma_e^-} \right) = \frac{\sigma_c^2}{kT} \Rightarrow F_{B-F}$$

ITO	Organic
$n_\infty^- = 10^{20} \text{ cm}^{-3}; \quad \varepsilon_e^- = 9.3$	$P_c = 10^{21} \text{ cm}^{-3}; \quad \varepsilon_i = 3$
$\mu_e^- = 30 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$	$\mu_p = 10^{-6} \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$
$\kappa_\infty^- = 0.225 \text{ eV}$	$\sigma_c = 0.1 \text{ eV}$

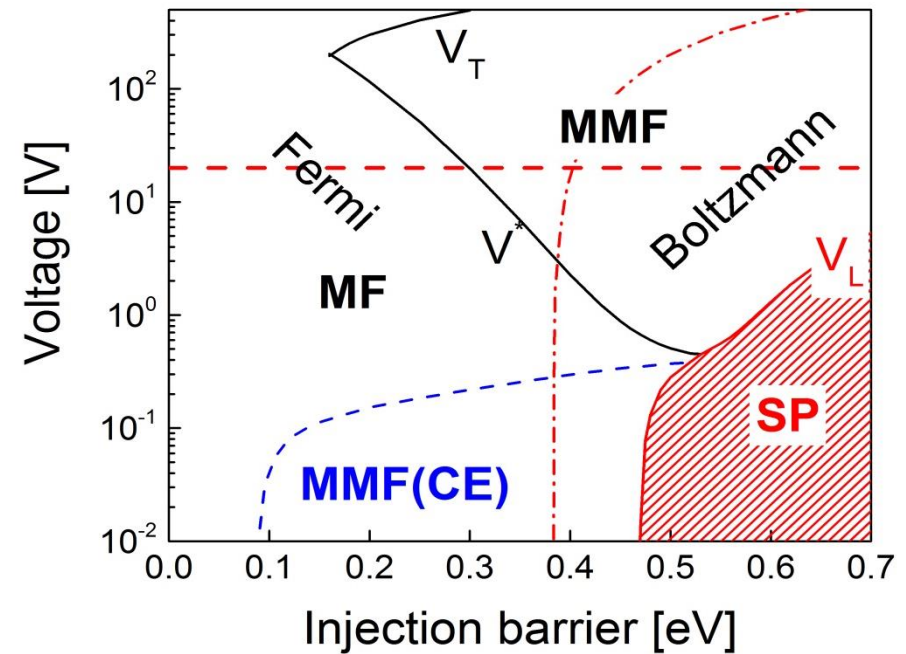


# Voltage-barrier chart for injecting electrode

## ITO/Organic/Al



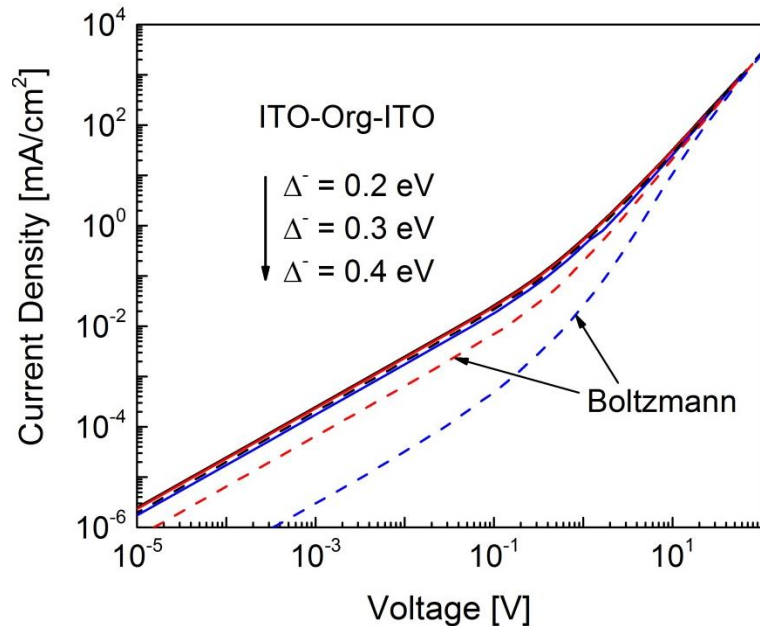
Boltzmann statistics only



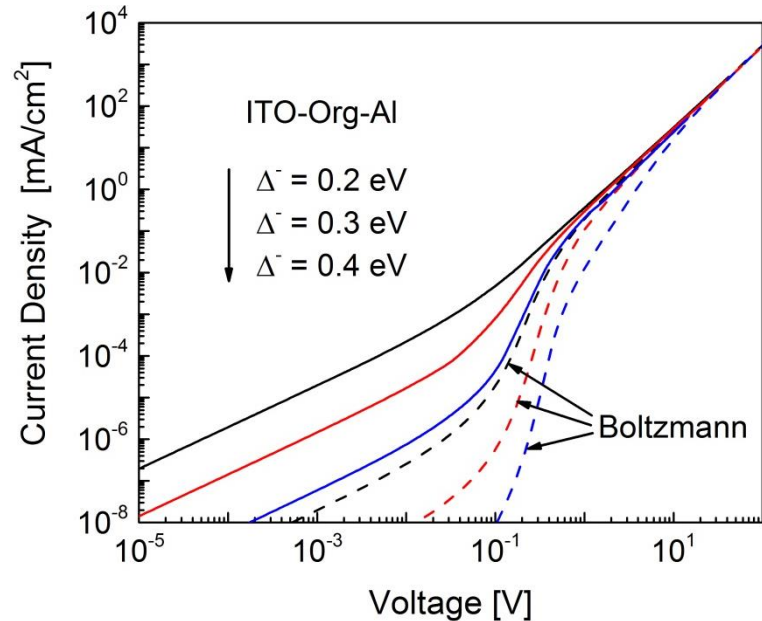
extended approach

# Simulated current-voltage characteristics

## ITO/OSC(100nm)ITO



## ITO/OSC(100nm)Al



- ❑ Assumption of the „Boltzmann regime“ for injected carriers results in sufficient undervaluing of calculated current density, especially at low voltages

# Conclusions

- The mean-field, self-consistent model of charge-carrier injection and transport in organic semiconductors accounting for discrete nature of charge carriers is extended to the case of degenerate OSC with the Gaussian shape of DOS
- The extended approach is applicable now for arbitrary values of injected carrier densities in the wide range of DOS parameters
- It is expected to improve the fitting of measured current-voltage characteristics, particularly at applied voltages near and well below the built-in potential value  
(Also, for fitting of fatigued bipolar IV characteristics –  
the challenge unresolved yet...)